

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/598,471 Confirmation No. 5838
Applicant : Yuichiro Shindo et al.
371 Filed : August 31, 2006
Art Unit : 1793
Examiner : Vanessa T. Velasquez
Customer No. : 00270
Title : HIGH-PURITY Ru POWDER, SPUTTERING TARGET
OBTAINED BY SINTERING THE SAME, THIN FILM
OBTAINED BY SPUTTERING THE TARGET AND PROCESS
FOR PRODUCING HIGH-PURITY Ru POWDER

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

This is an Amendment timely filed in response to a non-final Office Action dated January 5, 2009. Kindly amend the application as set forth below.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 6 of this paper.